SEMICONDUCTING POLYMER FIELD EFFECT TRANSISTOR

This application claims the benefit of U.S. Provisional Application Serial No. 60/116,112, filed January 15, 1999.

The instant invention is in the field of transistors. More specifically, the instant invention is in the field of transistors based on semiconducting polymers.

Transistors are important electronic devices. Metal oxide semiconductor field effect transistors (MOS FET) are well-known.

A field effect transistor comprises five elements. The first element is an insulator layer, the insulator layer being an electrical insulator, the insulator layer having a first side and a second side. The second element is a gate, the gate being an electrical conductor, the gate being positioned adjacent the first side of the insulator layer. The third element is a semiconductor layer, the semiconductor layer comprising a polymer, at least ten weight percent of the monomer units of the polymer being selected from a 9-substituted fluorene unit and a 9,9-substituted fluorene unit, the semiconductor layer having a first side, a second side, a first end and a second end, the second side of the semiconductor layer being adjacent the second side of the insulator layer. The fourth element is a source, the source being an electrical conductor, the source being in electrical contact with the first end of the semiconductor layer. The fifth element is a drain, the drain being an electrical conductor, the drain being in electrical contact with the second end of the semiconductor layer. A negative voltage bias applied to the gate causes the formation of a hole conduction channel in the semiconductor layer connecting the source to the drain. A positive bias applied to the gate causes the formation of an electron-conducting channel in the semiconductor layer.

Fig. 1 is a cross-sectional side view of an embodiment of the instant invention.

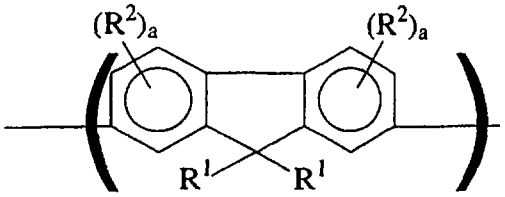
The instant invention is termed herein as a "metal-insulator-semiconductor field effect transistor" (MISFET). The MISFET comprises a semiconductor layer adjacent an insulator layer. Two electrodes (source and drain) are attached to the semiconductor layer and a third electrode (gate) is positioned adjacent the other side of the insulator layer. The semiconductor layer comprises a polymer. At least ten weight percent of the monomer units of the polymer are selected a 9-substituted fluorene unit and a 9,9-substituted fluorene unit. In a p-type field effect transistor, applying a negative DC voltage to the gate electrode induces an accumulation of "holes" near the insulator side of the semiconductor layer, creating a conduction channel through which electric current can flow by hole transport between the source and the drain so that the MISFET is in the "on" state. Zeroing the gate voltage causes

(for example, polyimides, poly(methylmethacrylate), polysulfene, etc.), an inorganic oxide (for example, GeO, CaO, SiO, MgO, SiO_2, SnO, SnO_2), an inorganic fluoride (for example, CsF, CaF_2, MgF_2, LiF), and an inorganic nitride (for example, Si_3N_4). The thickness of the insulator layer 11 is most preferably as thin as possible while maintaining electrical insulation between the gate 14 and the semiconductor layer 15 within the voltage rating of the embodiment 10.

The semiconductor layer 15 is then formed onto the insulating layer by, for example, standard solution processes. The semiconductor layer 15 comprises a polymer. At least ten weight percent (preferably at least 20 weight percent and more preferably at least 30 weight percent) of the monomer units of the polymer being selected from a 9-substituted fluorene unit and a 9,9-substituted fluorene unit.

Examples of such polymers are described in United States Patent 5,708,130; United States Patent 5,777,070, United States Patent Application Serial Number 08/861,469 filed May 21, 1997; United States Patent 5,962,631; and WO99/54385.

Specifically, the polymers, preferably, have groups of the formula

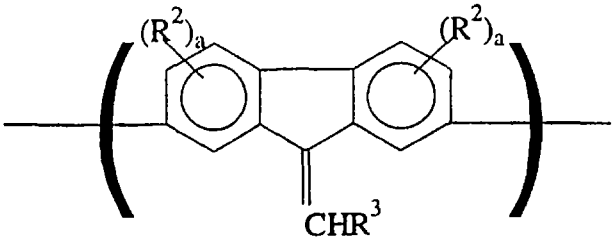


(IV)

wherein R^1 is independently in each occurrence C_{1-20} hydrocarbyl or C_{1-20} hydrocarbyl containing one or more S, N, O, P or Si atoms, C_{4-16} hydrocarbyl carbonyloxy, C_{4-16} aryl(trialkylsiloxy) or both R^1 may form with the 9-carbon on the fluorene ring a C_{5-20} ring structure or a C_{4-20} ring structure containing one or more heteroatoms of S, N or O;

R^2 is independently in each occurrence C_{1-20} hydrocarbyl, C_{1-20} hydrocarbyloxy, C_{1-20} thioether, C_{1-20} hydrocarbylcarbonyloxy or cyano and

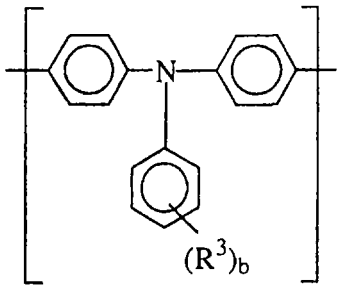
A is independently in each occurrence 0 or 1; and/or groups of the formula:



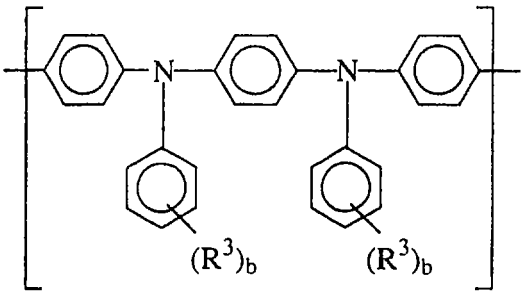
(V)

wherein R^2 and a are as defined above, and R^3 is independently in each occurrence C_{1-20} hydrocarbyl or C_{1-20} hydrocarbyl substituted with di(C_{1-20} alkyl)amino, C_{1-20} hydrocarbyloxy or C_{1-20} hydrocarbyl or tri(C_{1-10} alkyl)siloxy.

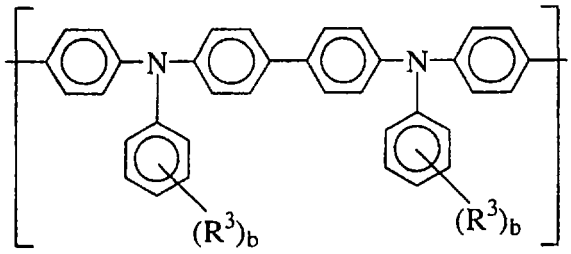
Comonomeric groups that may be used include:



(II),



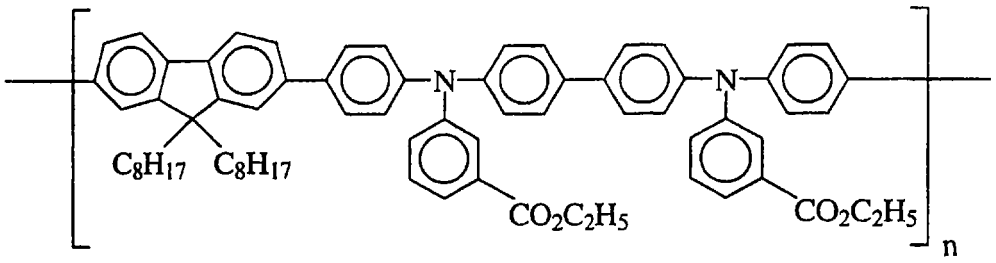
(III), and



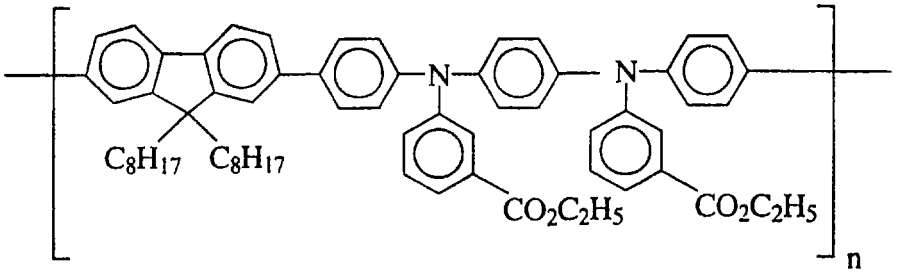
(IV)

R^3 is independently in each occurrence carboxyl, C_1-C_{20} alkyl, C_1-C_{20} alkoxy or a group of the formula $-CO_2R^4$ wherein R^4 is a C_1-C_{20} alkyl; and

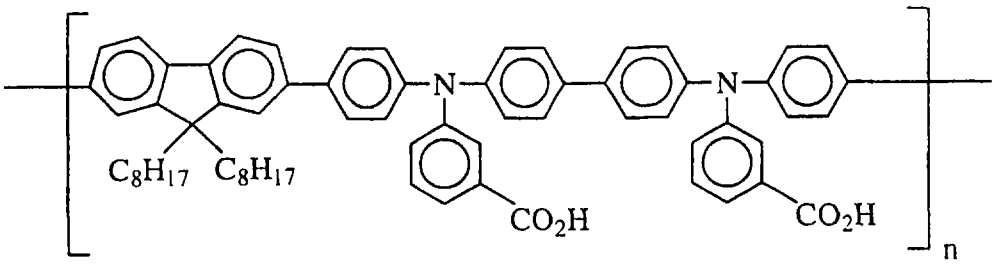
b is independently in each occurrence an integer from 0 to 3. Examples of such copolymers include:



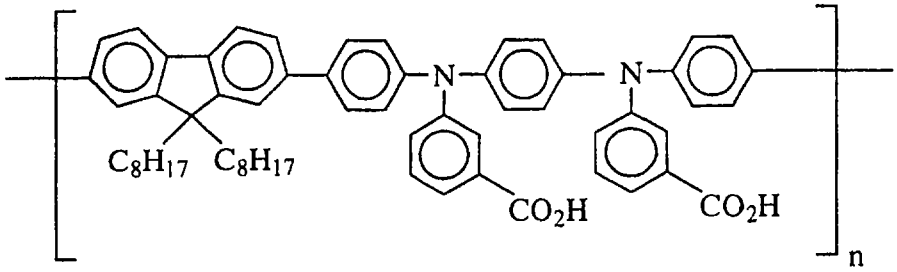
"BFE"
(V)



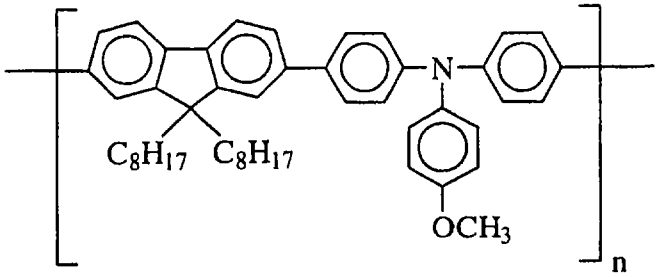
"PFE"
(VI)



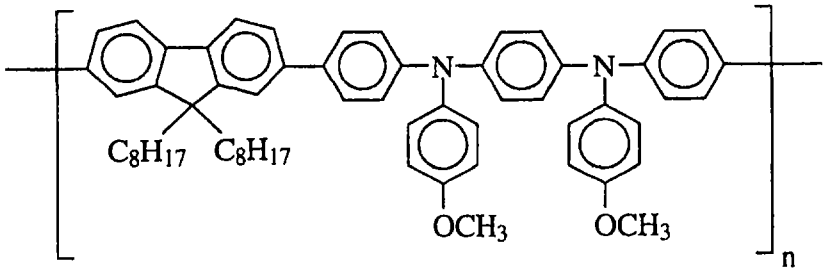
"BFA"
(VII)



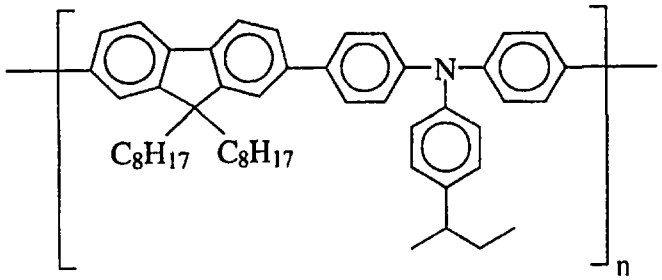
"PFA"
(VIII)



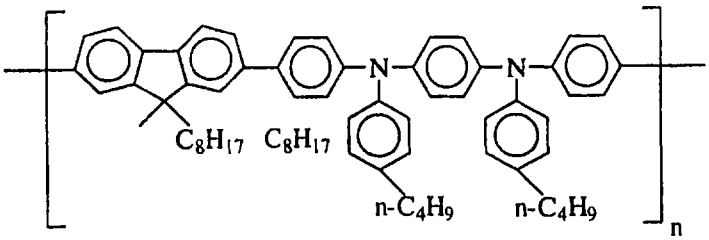
"TFMO"
(IX)



"PFMO"
(X)

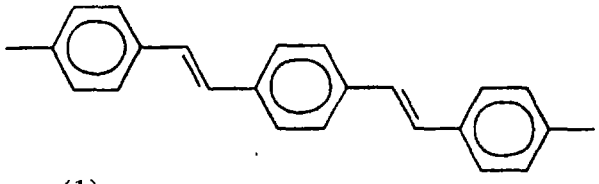


"TFB"
(XI)

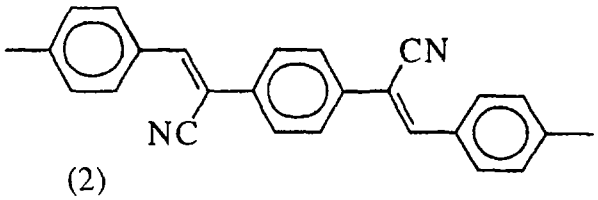


"PFB"
(XII)

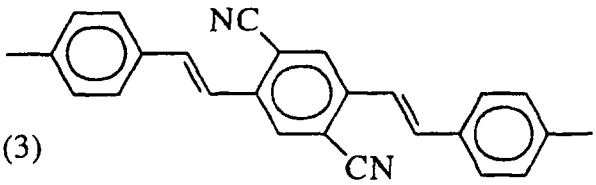
Other comonomeric groups include stilbene, tolan, C_6-C_{20} mononuclear/polynuclear aromatic hydrocarbons, and C_2-C_{10} mononuclear/polynuclear heterocycles. Examples of mononuclear/polynuclear aromatic hydrocarbons include benzene, naphthalene, acenaphthene, phenanthrene, anthracene, fluoranthene, pyrene, rubrene, and chrysene. Examples of mononuclear/polynuclear heterocycles include 5-member heterocycles such as furan, thiophene, pyrrole, oxazole, isooxazole, thiazole, isothiazole, imidazole, oxadiazoles, thiadiazole, and pyrazoles; 6-member heterocycles such as pyridine, pyridazine, pyrimidine, pyrazine, triazines, and tetrazenes; benzo-fused ring systems such as benzoxazole, benzothiazole, benzimidazole, quinoline, isoquinoline, cinnoline, quinazoline, quinoxaline, phthalazine, benzothiadiazole, and benzotriazines; and polynuclear condensed ring systems such as phenazine, phenanthridine, acridine, carbazole, and diphenylene oxide. In general, conjugated compounds containing up to 30 carbons are useful for the present purpose. They may be substituted optionally with one or more substituents that are not deleterious to the photoluminescent properties of the polymer compositions. Examples of substituents include C_1-C_{20} hydrocarbyl radicals, C_1-C_{20} (thio)alkoxy radicals, C_1-C_{20} (thio)aryloxy radicals, cyano, fluoro, chloro, C_1-C_{20} alkoxycarbonyl, C_1-C_{20} aryoxylcarbonyl, C_1-C_{20} carboxyl, and alkyl(aryl)sulfonyl radicals. Substituents which are known photoluminescent quenchers, such as arylcarbonyl and nitro, are undesirable. Conjugated monomeric units of more complex structures, as exemplified by Structures (1) - (8), may also be used.



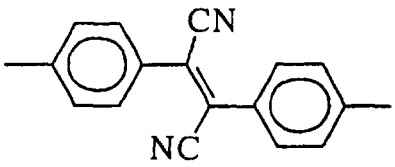
(1)



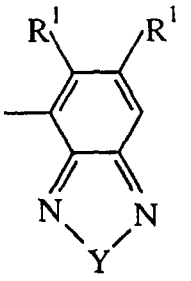
(2)



(3)

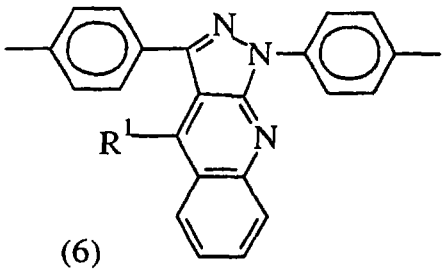


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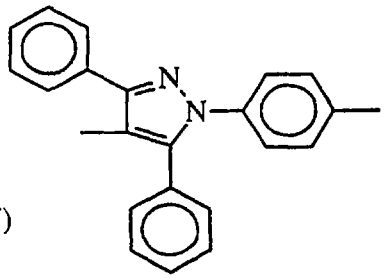


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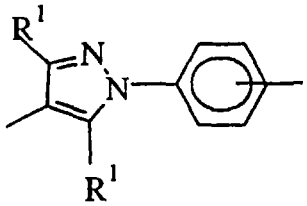
Y = S or O



(6)



(7)



(8)

Preferred fluorene-containing polymers are those with high carrier mobility as measured by standard techniques such as time-of-flight experiments as described by Van der Auweraer, *et al.* in Advanced Materials, Vol. 6, p. 199, 1994. More preferred are fluorene-containing polymers with non-dispersive carrier transport behavior, for example, poly(9,9-dioctylfluorene-2,7-diyl) described by Redecker, et *al.* in Applied Physics Letters, Vol. 73, p. 1565, 1998. Also preferred, are alternating fluorene copolymers with tertiary aromatic amines,

as described in the above referenced '469 and '187 United States Patent Applications. These polymers have carrier mobility of at least 1 x 10^{-4} cm^2/volt - second.

The semiconductor layer 15 may comprise a mixture of polymers. The polymer of the semiconductor layer 15 can be homogeneous or phase separated; it may also be amorphous, semicrytalline or liquid crystalline in morphology. The polymer may also be aligned in the liquid crystalline state for enhanced carrier mobility as described by Grell, *et al.* in Advanced Materials, Vol. 9, p. 798, 1997. The thickness of the semiconductor layer 15 is not critical and may vary, for example, from 1 nm to 1000 nm, preferably 10 nm to 500 nm, most preferably 20 nm to 100 nm.

The source 20 and the drain 21 can then be deposited, for example, through a mask by sputtering or thermal evaporation in vacuum. Preferred materials for the source 20 and the drain 21 are gold, silver, or aluminum. A negative bias applied to the gate causes the formation of a conduction channel in the semiconductor layer 15 at or near its interface with the insulator 11. A current flows from the source 20 to drain 21 when the latter is made negative relative to the former. The MISFET of this invention are characterized by high on-off ratio and field effect mobility.

What is claimed is:

1. A field effect transistor, comprising:

(a) an insulator layer, the insulator layer being an electrical insulator, the insulator layer having a first side and a second side;

(b) a gate, the gate being an electrical conductor, the gate being positioned adjacent the first side of the insulator layer;

(c) a semiconductor layer, the semiconductor layer comprising a copolymer of at least one fluorene-based monomer and at least one other conjugated monomer containing up to 30 carbon atoms, which other monomer is not a fluorene, at least ten weight percent of the monomer units of the copolymer being selected from the group consisting of a 9-substituted fluorene unit and a 9,9-substituted fluorene unit, the semiconductor layer having a first side, a second side, a first end and a second end, the second side of the semiconductor layer being adjacent the second side of the insulator layer;

(d) a source, the source being an electrical conductor, the source being in electrical contact with the first end of the semiconductor layer; and

(e) a drain, the drain being an electrical conductor, the drain being in electrical contact with the second end of the semiconductor layer.

2. The transistor of claim 1, wherein the semiconductor layer consists essentially of the copolymer.

3. The transistor of claim 1, wherein at least 20 weight percent of the monomer units of the copolymer are selected from the group consisting of a 9-substituted fluorene unit and a 9,9-substituted fluorene unit.

4. The transistor of claim 1, wherein at least 30 weight percent of the monomer units of the copolymer are selected from the group consisting of a 9-substituted fluorene unit and a 9,9-substituted fluorene unit.

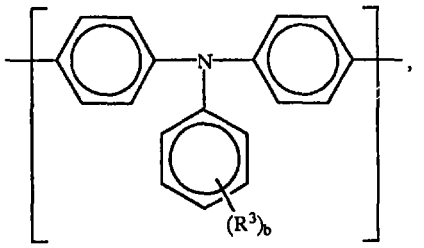
5. The transistor of claim 1, wherein the semiconductor layer is in direct contact with the insulator layer and wherein the gate is in direct contact with the insulator layer.

6. The transistor of claim 1 wherein the other conjugated monomer is selected from the group consisting of aromatic amines, stilbenes, tolanes, C_6-C_{20} mononuclear or polynuclear aromatic hydrocarbons, and C_2-C_{10} mononuclear or polynuclear heterocycles.

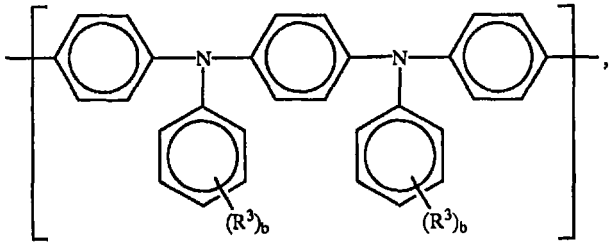
7. The transistor of claim 1 wherein the other conjugated monomer is thiophene.

8. The transistor of claim 1 wherein the other monomer is selected from

(II)

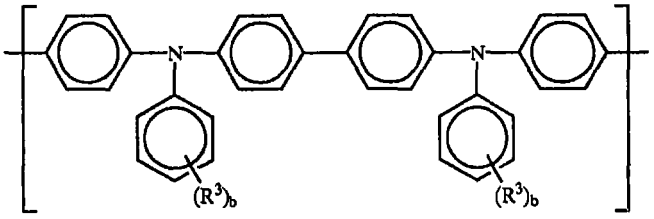


(III)



, and

(IV)



wherein R_3 is independently, in each occurrence, carboxyl, C_1-C_{20} alkyl, C_1-C_{20} alkoxy or a group of the formula $—CO_2R^4$, wherein R^4 is a C_1-C_{20} alkyl; and

b is independently, in each occurrence, an integer from 0 to 3.

9. The transistor of claim 1 wherein the copolymer is an alternating copolymer.

10. The transistor of claim 1 wherein the copolymer is aligned.

11. The transistor of claim 1 wherein the copolymer has a carrier mobility of at least 1×10^4 cm^2/volt-second.